

Half-metallic interface and coherent tunneling in $\text{Co}_2\text{YZ}/\text{MgO}/\text{Co}_2\text{YZ}$ ($\text{YZ}=\text{MnSi}, \text{CrAl}$) magnetic tunnel junctions: A first-principles study

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We present first-principles based calculations of electronic structures and tunneling conductance of $\text{Co}_2\text{YZ}/\text{MgO}$ (~ 2 nm)/ $\text{Co}_2\text{YZ}(001)$ ($\text{YZ}=\text{MnSi}, \text{CrAl}$) magnetic tunnel junctions (MTJs). It is found that $\text{YZ}(\text{MnSi}$ and $\text{CrAl})$ -terminated interfaces are thermodynamically stable as compared with Co-terminated interfaces in $\text{Co}_2\text{YZ}/\text{MgO}(001)$ junctions. In the CrAl-termination, no interface states appear in both sides of the junctions, preserving the half metallicity of Co_2CrAl , while reduction of the spin polarization is significant in the MnSi termination. Co_2CrAl , however, has no Δ_1 band at the Fermi level, thus the majority-spin conductance of $\text{Co}_2\text{CrAl}/\text{MgO}/\text{Co}_2\text{CrAl}(001)$ MTJs in the parallel magnetization is much smaller than that of $\text{Co}_2\text{MnSi}/\text{MgO}/\text{Co}_2\text{MnSi}(001)$ MTJs. We propose that MTJs having an ultrathin Co_2CrAl layer between Co_2MnSi electrode and MgO barrier, i.e., $\text{Co}_2\text{MnSi}/\text{Co}_2\text{CrAl}/\text{MgO}(001)$ junctions, can derive both the half-metallic character at the interface and the large tunneling conductance through the Δ_1 channel in the parallel magnetization.

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I. INTRODUCTION

The spin-dependent tunneling between ferromagnetic electrodes separated by insulating barriers provides the tunneling magnetoresistance (TMR) depending on relative magnetization directions of the two ferromagnetic electrodes.^{1,2} The effect is essential for applications of spintronics such as the magnetoresistive random access memory (MRAM) and the read-out head of hard disk drives. The half-metallic ferromagnets (HMFs), which are metallic for the majority-spin state and semiconducting with an energy gap for the minority-spin state, leading to complete (100%) spin polarization at the Fermi level are one of key materials in obtaining huge TMR.

Among the many theoretically predicted HMFs,³⁻⁹ the Co-based full Heusler alloys are the most promising candidates for use in spintronics devices owing to their high Curie temperatures above room temperature¹⁰ (RT) and robustness of high spin polarization against atomic disorder.^{11,12} Many experiments have been conducted on TMR measurements for MTJs with an amorphous alumina (AlO_x) barrier and Co-based full Heusler alloys, e.g., $\text{Co}_2(\text{Cr}_{0.6}\text{Fe}_{0.4})\text{Al}$,¹³ Co_2MnAl ,¹⁴ Co_2FeAl ,¹⁵ Co_2MnSi ,¹⁶ and $\text{Co}_2\text{Fe}(\text{Al}_{0.5}\text{Si}_{0.5})$.¹⁷ In particular, a large TMR ratio of 570% has been observed at 2 K for the $\text{Co}_2\text{MnSi}/\text{AlO}_x/\text{Co}_2\text{MnSi}$ MTJ.¹⁶ It confirms the high spin polarization of Co_2MnSi experimentally for the first time. However, the TMR ratio decreases rapidly with increasing temperature and reaches 67% at RT.

Recently, TMR ratio as high as 6000% was predicted in the $\text{Fe}/\text{MgO}/\text{Fe}(001)$ MTJ from a ballistic conductance calculations.^{18,19} It was found that the decay of the wave function with Δ_1 symmetry is very slow as compared with that of Δ_2 and Δ_5 channels in the single crystalline MgO barrier owing to the symmetry compatibility with the complex Δ_1 band in the insulating gap of the MgO. Since bcc-Fe is half metallic on the Δ_1 band, the $\text{Fe}/\text{MgO}/\text{Fe}(001)$ MTJ can provide very large TMR. In fact, high TMR ratios of about 180% for the $\text{Fe}/\text{MgO}/\text{Fe}(001)$ MTJ (Ref. 20) and

about 220% for $\text{CoFe}/\text{MgO}/\text{CoFe}(001)$ MTJ (Ref. 21) have been obtained at RT. Furthermore, the TMR ratio was raised to 500% at RT for the MTJ with CoFeB electrodes and a MgO barrier.²²

While the $\text{Fe}/\text{MgO}/\text{Fe}(001)$ MTJ and related systems have succeeded in obtaining very large TMR ratio at RT, lower resistance has been required to achieve ultrahigh speed and high density in future spintronics applications. To this end, one needs a tunneling junction with a thin MgO barrier. However, the TMR ratio of $\text{Fe}/\text{MgO}/\text{Fe}(001)$ and related systems rapidly decreases with the decreasing MgO barrier thickness owing to the contribution of the minority-spin Δ_5 and Δ_2 channels to the tunneling conductance through a thin MgO barrier. The use of the HMF as an electrode in the MTJ with MgO barrier (HMF/MgO/HMF) can be expected to suppress the tunneling from the minority-spin Δ_5 and Δ_2 states in such a thin MgO barrier and has a potential to overcome this problem.

The MTJs composed of the MgO barrier and half-metallic Co-based full Heusler alloys, e.g., $\text{Co}_2\text{Fe}(\text{Al}_{0.5}\text{Si}_{0.5})$,²³ $\text{Co}_2(\text{Cr}_{0.6}\text{Fe}_{0.4})\text{Al}$,²⁴ and Co_2MnSi ,²⁵ were fabricated in recent years, and the TMR ratio has been improved steadily. However, the TMR ratio still depends on temperature considerably because the tunneling conductance in the antiparallel magnetization increases with increasing temperature. For example, high TMR ratio of 683% observed at 4.2 K for the $\text{Co}_2\text{MnSi}/\text{MgO}/\text{Co}_2\text{MnSi}$ MTJ (Ref. 25) decreases to 179% at RT. It is considered that the thermal fluctuation of magnetic spin moments²⁶ of the HMF electrodes causes incoherent or nonquasiparticle states in the minority-spin gap and gives rise to the reduction of the spin polarization and considerable contributions to the tunneling conductance of MTJs in the antiparallel magnetization.²⁷ Furthermore, Mavropoulos *et al.*²⁸ suggested that interface states appeared in the minority-spin gap at the junctions of MTJs can also contribute to the tunneling conductance in the antiparallel magnetization through spin mixing processes such as magnon excitations and inelastic scattering at RT.

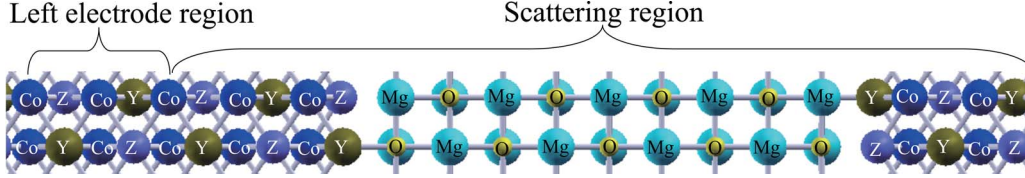


FIG. 1. (Color online) A supercell of the $\text{Co}_2\text{YZ}/\text{MgO}/\text{Co}_2\text{YZ}$ ($\text{YZ}=\text{MnSi}$ or CrAl) MTJ with YZ termination and corresponding left electrode and scattering regions assumed in conductance calculations (see text).

In this paper, we perform first-principles electronic structure calculations and ballistic conductance calculations in order to clarify electronic and transport properties of MTJs with Co_2YZ ($\text{YZ}=\text{MnSi}, \text{CrAl}$) and MgO barriers. First, we carefully determine stable interfacial structures at $\text{Co}_2\text{YZ}/\text{MgO}(001)$ junctions. We will show that $\text{YZ}(\text{MnSi}$ and $\text{CrAl})$ -terminated interfaces are thermodynamically stable as compared with Co -terminated interfaces. In particular, we find that the CrAl -terminated $\text{Co}_2\text{CrAl}/\text{MgO}(001)$ interface is half metallic without any interface states in both sides of the junctions, while the MnSi -terminated $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ interface loses the half metallicity of Co_2MnSi . The half-metallic character at interfaces is important to suppress the tunneling conductance through interface states in the antiparallel magnetization. Then, we will show that the majority-spin conductance of $\text{Co}_2\text{CrAl}/\text{MgO}/\text{Co}_2\text{CrAl}$ (001) MTJs in the parallel magnetization is much smaller than that of $\text{Co}_2\text{MnSi}/\text{MgO}/\text{Co}_2\text{MnSi}$ (001) MTJs owing to the absence of the Δ_1 band around the Fermi level in Co_2CrAl . It is considered that the Δ_1 band in the majority-spin state is also essential to obtain a large TMR ratio for MgO -based MTJs. Here, we propose that addition of an ultrathin Co_2CrAl layer between Co_2MnSi electrode and MgO barrier can eliminate interface states while preserving the coherent tunneling through the Δ_1 band of the MTJ in the parallel magnetization.

II. COMPUTATIONAL METHOD

We perform first-principles calculations for supercells consisting of Co_2YZ ($\text{YZ}=\text{MnSi}$ or CrAl) and MgO using the density-functional theory within the generalized-gradient approximation for the exchange-correlation energy.²⁹ In order to facilitate the structure optimization, which is important for determining the interface structure, we adopt plane-wave basis sets along with the ultrasoft pseudopotential method by using the quantum code ESPRESSO.³⁰ The number of \mathbf{k} points is taken to be $10 \times 10 \times 1$ for all cases, and Methfessel-Paxton smearing with a broadening parameter of 0.01 Ry is used. The cutoff energy for the wave function and charge density is set to 30 and 300 Ry, respectively. These values are large enough to deal with all the elements considered here within the ultrasoft pseudopotential method.

A $\text{Co}_2\text{YZ}/\text{MgO}/\text{Co}_2\text{YZ}(001)$ MTJ is constructed in a tetragonal supercell, where the in-plane lattice parameter of the supercell is fixed at 3.99 and 4.05 Å for $\text{YZ}=\text{MnSi}$ and CrAl , respectively. These values correspond to $a_0/\sqrt{2}$, where a_0 is the lattice constant of the bulk Co_2MnSi (5.65 Å) and

Co_2CrAl (5.73 Å). Since the lattice constant of the rock salt MgO is 4.21 Å, the lattice mismatches between Co_2YZ and MgO on the 45° in-plane rotation at (001) face are 5.1% for Co_2MnSi and 3.8% for Co_2CrAl , which lead to 11.2% and 8.3% of tetragonal expansions along longitudinal (z axis) direction in MgO , respectively. The $\text{Co}_2\text{YZ}/\text{MgO}(001)$ interface has two types of termination on Co_2YZ , namely, the Co termination and the YZ termination. We prepare the supercell of multilayer containing nine atomic layers of MgO and 17 and 15 atomic layers of Co_2YZ for the Co - and YZ -terminated interfaces, respectively. Figure 1 schematizes the supercell of the $\text{Co}_2\text{YZ}/\text{MgO}(9)/\text{Co}_2\text{YZ}(001)$ MTJ for the YZ termination. The supercell of the Co termination has two more Co atoms at both sides of the MgO junctions in the supercell of the YZ termination.

For conductance calculations, we consider an open quantum system consisting of a scattering region corresponding to MgO and a junction with Co_2YZ attached to left and right semi-infinite electrodes corresponding to bulk Co_2YZ . Conductance is obtained by solving the scattering equation with infinite boundary conditions in which the wave function of the scattering region and its derivative are connected to the Bloch states of each electrode.³¹ The potential in the scattering equation can be obtained from the self-consistent electronic structure calculations for the supercell containing a left and a scattering region. Corresponding left electrode and scattering region used in the conductance calculations are shown in Fig. 1. We confirmed that five atomic layers of Co_2YZ between the right edge of the electrode region and the left-hand side of the $\text{Co}_2\text{YZ}/\text{MgO}$ interface are enough to represent the shape of the local potential of bulk Co_2YZ in the electrode region.

Since our system is repeated periodically in the xy plane and propagating states can be assigned by an in-plane wave vector $k_{\parallel}=(k_x, k_y)$ index, different k_{\parallel} do not mix and can be treated separately. Furthermore, our approach neglects the spin-orbit interaction and noncollinear spin configuration. Thus, we solve scattering equations for some fixed k_{\parallel} and spin index on the basis of approaches of Choi and Ihm.^{31,32}

III. RESULTS AND DISCUSSION

A. Interfacial structure of $\text{Co}_2\text{YZ}/\text{MgO}(001)$

The $\text{Co}_2\text{YZ}/\text{MgO}(001)$ junction has three possible configurations for each termination where atoms terminating Co_2YZ are positioned: on top of the O atoms (O-top), Mg atoms (Mg-top), or hollow of the $\text{MgO}(001)$ surface. In order to determine the stable interfacial configuration for each termination in $\text{Co}_2\text{YZ}/\text{MgO}(001)$ junctions, we minimized the

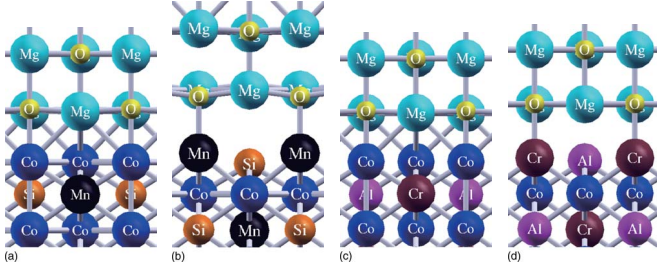


FIG. 2. (Color online) Magnifications of the cross-sectional view of (a) Co- and (b) MnSi-terminated $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ interface and (c) Co- and (d) CrAl-terminated $\text{Co}_2\text{CrAl}/\text{MgO}(001)$ interfaces with the O-top configuration, where atoms terminating Co_2YZ are positioned on top of the O atoms in the $\text{MgO}(001)$ surface. The atomic position is determined so as to minimize the total energy of each termination.

total energy by relaxing atomic positions except for atoms in the electrode region with changing the longitudinal size of the supercell. We found that the O-top configuration is most stable among the other configurations (Mg-top and hollow) owing to the hybridization between $3d_{3z^2-r^2}$ orbital of the transition atoms (Co, Mn, and Cr) and p_z orbital of O atom. The magnifications of the $\text{Co}_2YZ/\text{MgO}(001)$ interfacial structure with O-top configuration are schematized in Fig. 2 for each termination, which shows how the interfacial atoms move after the relaxations.

As can be seen in Figs. 2(a) and 2(c), the Co-terminated interface has a simple structure with 2.0 Å of interfacial distance both for the $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ and $\text{Co}_2\text{CrAl}/\text{MgO}(001)$ junctions. On the other hand, structures of the YZ-terminated interface are a little bit complicated. For instance, in the case of the MnSi termination, the Mn-O distance is 2.25 Å, while the Si-O distance is 3.17 Å. This can be attributed to the difference in the covalent bond radii of Mn and Si atoms. Since the covalent bond radius of the Si atom (1.11 Å) is smaller than that of the Mn atom (1.39 Å), the interfacial Si atom of the MnSi termination cannot keep the Co-Si distance of the bulk Co_2MnSi (2.42 Å). Consequently, the Si atom moves toward the Co atom side and only the Mn atom makes a bond with the O atom. In fact, the Co-Si distance (2.33 Å) of the MnSi termination corresponds to that of the bulk CoSi_2 with Fluorite (C1) structure (2.32 Å). Similar structure is observed in the CrAl-terminated interface because of the difference in the covalent bond radius of Cr (1.27 Å) and Al atoms (1.18 Å), while the Cr-O and Al-O distances (2.20 and 2.34 Å) are smaller than those of the MnSi-terminated interface.

The relative stability between the Co- and YZ-terminated interfaces is given by the formation energy

$$E_{\text{form}}^{\text{term}} = E_{\text{tot}}^{\text{term}} - \sum_i N_i \mu_i, \quad (1)$$

where $E_{\text{tot}}^{\text{term}}$ is the total energy of the supercell for each termination, N_i the number of atoms of each element, and μ_i their chemical potentials. At equilibrium, the chemical potential of the constituent atoms cannot exceed the corresponding one of the bulk phase, i.e., upper limit of μ_i can be derived

TABLE I. The formation energy difference between the Co- and YZ-terminated interfaces $E_{\text{form}}^{\text{diff}}$ for the Co-rich and Co-poor limits. The positive (negative) value of $E_{\text{form}}^{\text{diff}}$ indicates that the YZ-terminated interface is more (less) stable than the Co-terminated interface. $\mu_{\text{Co}(\text{rich})} - \mu_{\text{Co}(\text{poor})}$ means the difference of the chemical potential between the Co-rich and Co-poor limits (see text).

(eV)	$\text{Co}_2\text{MnSi}/\text{MgO}$	$\text{Co}_2\text{CrAl}/\text{MgO}$
$\mu_{\text{Co}(\text{rich})} - \mu_{\text{Co}(\text{poor})}$	0.967	0.455
$E_{\text{form}}^{\text{diff}}(\text{Co-poor})$	1.91	1.19
$E_{\text{form}}^{\text{diff}}(\text{Co-rich})$	-0.0249	0.282

from the bulk total energy per atom. Here, $\mu_{\text{Co}(\text{bulk})}$ is taken from hcp-Co, $\mu_{\text{Mn}(\text{bulk})}$ and $\mu_{\text{Cr}(\text{bulk})}$ from antiferromagnetic α -Mn and bcc-Cr, and $\mu_{\text{Si}(\text{bulk})}$ and $\mu_{\text{Al}(\text{bulk})}$ from diamond structure Si and fcc-Al, respectively. Since each supercell is nonstoichiometric only on Co atom, the difference of the formation energy between Co and YZ termination $E_{\text{form}}^{\text{diff}} = (E_{\text{form}}^{\text{Co term}} - E_{\text{form}}^{\text{YZ term}})/2$ can be expressed as function of μ_{Co} only. Furthermore, assuming the thermodynamic equilibrium condition $\mu_{\text{Co}_2YZ} = 2\mu_{\text{Co}} + \mu_Y + \mu_Z$ and taking μ_{Co_2YZ} from the bulk structure, we can determine the lower limit of μ_{Co} as $\mu_{\text{Co}} \geq \mu_{\text{Co}_2YZ} - \mu_Y(\text{bulk}) - \mu_Z(\text{bulk})$, i.e., the formation energy difference is expressed within the thermodynamically allowed range $\mu_{\text{Co}_2YZ} - \mu_Y(\text{bulk}) - \mu_Z(\text{bulk}) \leq \mu_{\text{Co}} \leq \mu_{\text{Co}(\text{bulk})}$. It is conventional to refer to the upper limit of μ_{Co} as the Co-rich limit and to the lower limit as the Co-poor limit.

Table I shows the $E_{\text{form}}^{\text{diff}}$ for the $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ and $\text{Co}_2\text{CrAl}/\text{MgO}(001)$ junctions with the O-top configuration for the Co-rich and Co-poor limits. The positive (negative) value of $E_{\text{form}}^{\text{diff}}$ indicates that the YZ-terminated interface is more (less) stable than the Co-terminated interface. In the Co-rich case of the $\text{Co}_2\text{MnSi}/\text{MgO}(001)$, the Co termination is slightly stable as compared with the MnSi termination. However, in the wide range of the μ_{Co} , the MnSi termination is more favorable than the Co termination. Furthermore, in the case of the $\text{Co}_2\text{CrAl}/\text{MgO}(001)$, the CrAl termination is more stable than the Co termination irrespective of the μ_{Co} . We consider that the relaxations of atomic positions in the YZ-terminated interfaces significantly reduce the formation energy of the supercell. These results are consistent with the formation energy calculations for the $\text{Co}_2\text{MnSi}(001)$ surface, where the MnSi-terminated surface is more stable than the Co-terminated surface.³³

In our previous study,³⁴ we adopted the Co termination as an interfacial structure of the $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ junction because of its large adhesion energy as compared with that of the MnSi termination. In experiments, the Co_2YZ film is annealed after deposition on a buffer layer in order to obtain ordered $L2_1$ structures. This means that a thermodynamically stable structure, i.e., the YZ-terminated interface will appear in the Co_2YZ/MgO junction. Thus, in this paper, we focus on the YZ-terminated interface of the $\text{Co}_2YZ/\text{MgO}(001)$ junction and discuss its electronic structures and transport properties.

B. Electronic structure of $\text{Co}_2YZ/\text{MgO}(001)$

Figure 3 shows majority- and minority-spin local density of states (LDOSs) at the Fermi level projected on to each

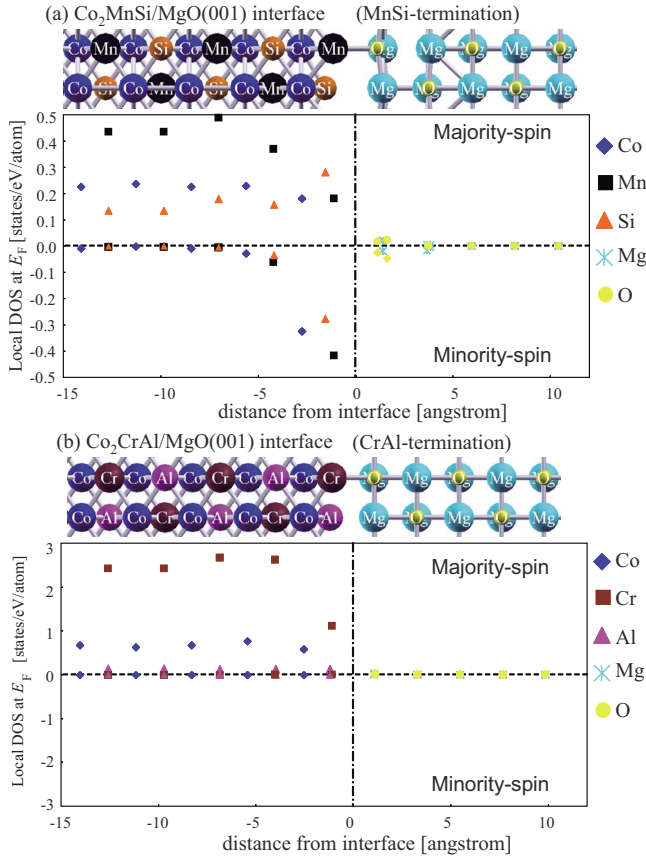


FIG. 3. (Color online) The local density of states (LDOSs) at the Fermi level projected on to each atomic sphere as a function of the distance from interface for (a) $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ and (b) $\text{Co}_2\text{CrAl}/\text{MgO}(001)$ junctions, respectively. The positive (negative) sign of y axis indicates majority-spin (minority-spin) LDOS. Schematic figures of the supercell of the $\text{Co}_2\text{YZ}/\text{MgO}/\text{Co}_2\text{YZ}(001)$ MTJ are shown above the LDOS, respectively.

atomic sphere as a function of the distance from the $\text{Co}_2\text{YZ}/\text{MgO}(001)$ junction. It is found that in the case of the MnSi termination, interface states appear in the minority-spin state at the Fermi level, reducing the half metallicity of the Co_2MnSi . Similar results have been obtained in the Co termination of the $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ junction.³⁴ In contrast, the CrAl termination has no interface states in the minority-spin state at the Fermi level in both sides of the junctions.

To see electronic structures at interface in more detail, we present in Figs. 4 and 5 the majority- and minority-spin LDOSs of each atom and atomic orbital in the YZ-terminated $\text{Co}_2\text{YZ}/\text{MgO}(001)$ interface. The LDOSs in the bulk (electrode) region are also shown as a reference. In Figs. 4(a) and 4(b), minority-spin states are observed around the Fermi level in the LDOSs of the interfacial Mn and Si atoms. The spin polarizations of interfacial Mn and Si are -40% and 1.0% , respectively. At the interface, the Mn atom loses half of its first neighbor Co atoms, and nonbonding Mn $3d$ states (possibly d_{yz} , d_{zx} , and $d_{3z^2-r^2}$) can appear around the Fermi level. Since the Mn $3d_{3z^2-r^2}$ orbital hybridizes with the O $2p_z$ orbital at the interface, the LDOSs of the interfacial Mn $3d_\gamma$ states keep half-metallic character. Contrary to this, interfa-

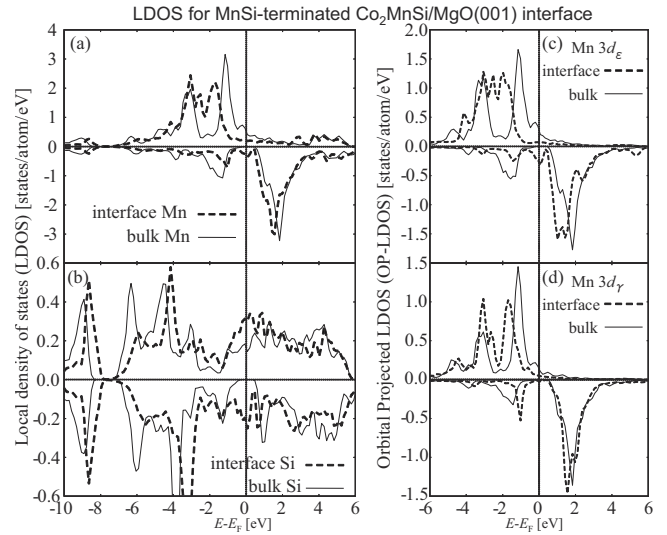


FIG. 4. Dashed lines show the local density of states of (a) Mn, (b) Si, (c) Mn $3d_\epsilon$, and (d) Mn $3d_\gamma$ at the MnSi-terminated $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ interface as a function of energy relative to the Fermi energy. The LDOSs in the bulk (electrode) region are also shown as a reference by solid line in each figure. The sign of LDOS indicates the majority-spin (positive) and minority-spin (negative) states.

cial Mn $3d_\epsilon$ orbital ($3d_{yz}$ and $3d_{zx}$) becomes nonbonding in the O-top configuration, reducing the spin polarization at the MnSi-terminated interface.

In Fig. 5, on the other hand, the LDOSs of the interfacial Cr and Al show the clear minority-spin gap, and the half-metallic character of Co_2CrAl is preserved at the CrAl terminated interface. It is important to refer that the (100) CrAl-terminated surface was previously predicted to have a high

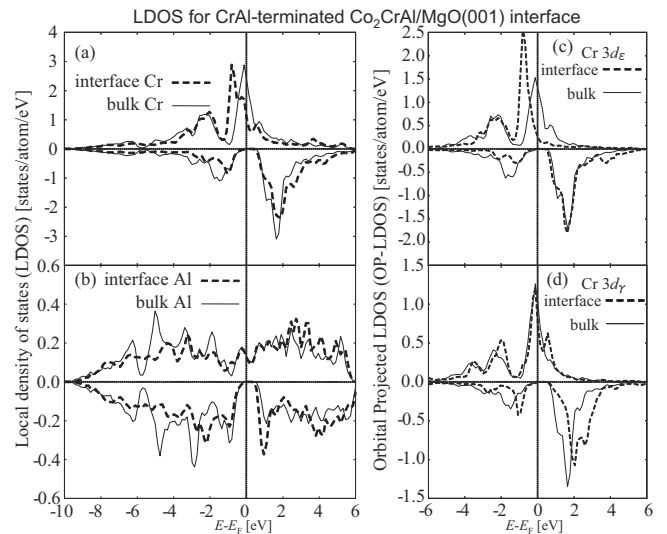


FIG. 5. Dashed lines show the local density of states of (a) Cr, (b) Al, (c) Cr $3d_\epsilon$, and (d) Cr $3d_\gamma$ at the CrAl-terminated $\text{Co}_2\text{CrAl}/\text{MgO}(001)$ interface as a function of energy relative to the Fermi energy. The LDOSs in the bulk (electrode) region are also shown as a reference by solid line in each figure. The sign of LDOS indicates the majority-spin (positive) and minority-spin (negative) states.

TABLE II. The local magnetization (μ_B) at the interface and bulk regions of the YZ -terminated $\text{Co}_2YZ/\text{MgO}(001)$ junctions ($YZ=\text{MnSi}, \text{CrAl}$).

(μ_B)				
$\text{Co}_2\text{MnSi}/\text{MgO}(001)$	Co	Mn	Si	O
Interfacial region	0.936	4.06	-0.185	-0.0342
Bulk region	0.935	3.31	-0.115	0.00
$\text{Co}_2\text{CrAl}/\text{MgO}(001)$	Co	Cr	Al	O
Interfacial region	0.832	3.10	-0.121	0.0110
Bulk region	0.712	1.78	-0.161	0.00

spin polarization of about 85%,³⁵ while the spin polarization is degraded significantly at the CrAl-terminated $\text{Co}_2\text{CrAl}/\text{GaAs}(100)$ interface.³⁶ Since the GaAs has narrow gap around the Fermi level as compared with the MgO, the half-metallic character of the CrAl-terminated surface is destroyed significantly once the surface is attached by GaAs.

Table II lists the local spin moments of Co, Y (Mn or Cr), Z (Si or Al), and O atoms at the interfacial region and in the bulk region. It is found that the spin moments of the interfacial Mn ($4.06 \mu_B$) and Cr ($3.10 \mu_B$) are larger than those of the bulk Co_2MnSi ($3.31 \mu_B$) and Co_2CrAl ($1.78 \mu_B$) because of the charge transfer from the minority-spin to the majority-spin states. We consider that the relaxation of the atomic positions and the reduced symmetry at the interface cause charge transfer from the minority-spin to the majority-spin $3d$ states owing to the localization effect of $3d$ electrons.

We should discuss why the CrAl termination is half metallic while the MnSi termination is not. In the case of

Co_2MnSi , the majority-spin Mn $3d_\epsilon$ states are nearly occupied [see Fig. 3(c)]. This suppresses the charge transfer in the interfacial region and leaves electrons in the nonbonding $3d_\epsilon$ states in the minority-spin gap, leading to the reduction of the spin polarization at the interface. On the other hand, in the case of Co_2CrAl , the majority-spin Cr $3d_\epsilon$ states are partially occupied [see Fig. 3(c)], and a large amount of minority-spin charge can transfer to the majority-spin states in the interfacial region. The charge transfer diminishes electrons in the nonbonding minority-spin Cr $3d_\epsilon$ states and acts to reconstruct the half-metallic gap in the LDOS of the interfacial Cr atom. In fact, the local spin moment of Cr in the CrAl-terminated interface is increased by $1.35 \mu_B$ from the bulk one, which is larger than that of Mn atom in the MnSi-terminated interface (increased by $0.75 \mu_B$ from the bulk one). The large enhancement of the Cr spin moment is observed also in the CrAl-terminated surface.³⁵ It is considered that the large enhancement of the interfacial Cr spin moment is a result of the large amount of charge transfer from the minority-spin to the majority-spin Cr $3d_\epsilon$ states, leading to the half-metallic character of the CrAl termination.

C. Transport properties of $\text{Co}_2YZ/\text{MgO}/\text{Co}_2YZ$

We show in Fig. 6 the energy dependence of the transmittance at $k_{\parallel}=(0,0)$ for the $\text{Co}_2\text{MnSi}/\text{MgO}(9)/\text{Co}_2\text{MnSi}(001)$ MTJ (CMS/MgO/CMS) and the $\text{Co}_2\text{CrAl}/\text{MgO}(9)/\text{Co}_2\text{CrAl}(001)$ MTJ (CCA/MgO/CCA), respectively. The band structures of bulk Co_2MnSi and Co_2CrAl along the $[001]$ direction at $k_{\parallel}=(0,0)$ are presented for comparison. Note that these results show the zero-bias conductance at each energy and do not indicate the bias volt-

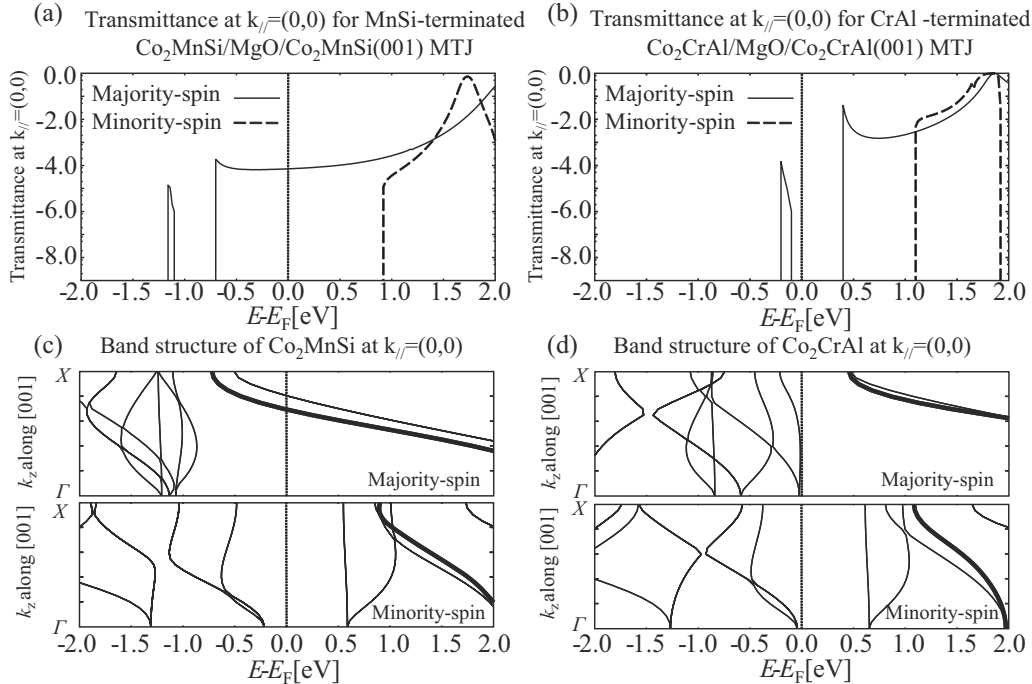


FIG. 6. The majority- and minority-spin transmittances as a function of energy at $k_{\parallel}=(0,0)$ for (a) $\text{Co}_2\text{MnSi}/\text{MgO}(9)/\text{Co}_2\text{MnSi}(001)$ and (b) $\text{Co}_2\text{CrAl}/\text{MgO}(9)/\text{Co}_2\text{CrAl}(001)$ MTJs in the parallel magnetization. The majority- and minority-spin band structures of bulk (c) Co_2MnSi and (d) Co_2CrAl along $[001]$ direction at $k_{\parallel}=(0,0)$ are also shown, where bold lines indicate the conduction band with Δ_1 symmetry. The scale of the vertical axis for transmittance is logarithmic.

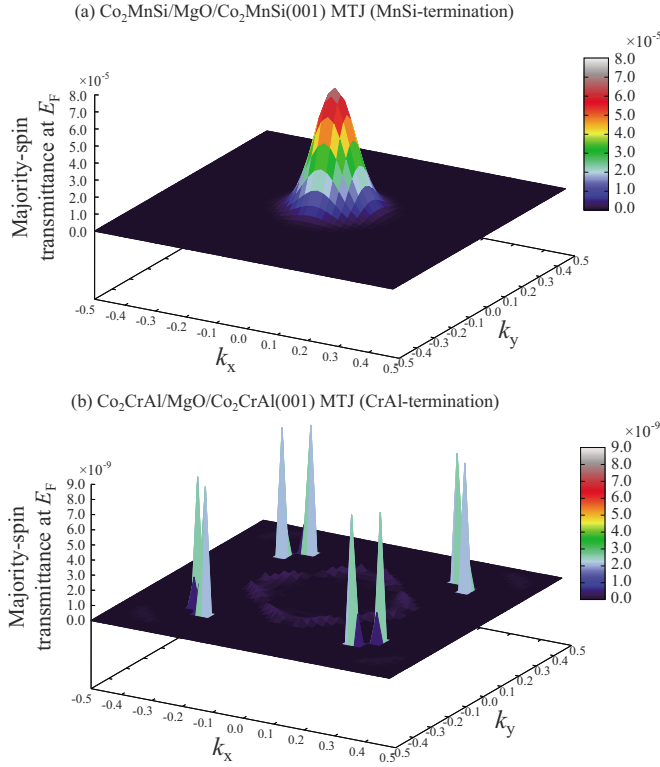


FIG. 7. (Color online) In-plane wave vector $k_{\parallel}=(k_x, k_y)$ dependence of majority-spin transmittance at the Fermi level for (a) $\text{Co}_2\text{MnSi}/\text{MgO}(9)/\text{Co}_2\text{MnSi}(001)$ and (b) $\text{Co}_2\text{CrAl}/\text{MgO}(9)/\text{Co}_2\text{CrAl}(001)$ MTJs in the parallel magnetization.

age dependence of conductance. It is found in both cases that the transmittance increases with increasing energy, and the thresholds coincide with the bottom of the broad conduction bands of bulk Co_2MnSi and Co_2CrAl . This means that the conduction bands are the main contributing factor to the transmittance at $k_{\parallel}=(0,0)$.

From the symmetry analysis of the Co_2MnSi band structure, we found that the majority-spin conduction band on the lower energy side [shown by bold solid line in Fig. 6(c)] has the Δ_1 symmetry. Furthermore, the majority-spin conduction band on the higher energy side is doubly degenerate and has the Δ_5 symmetry. Similarly, the unoccupied conduction band in the majority-spin state on the lower energy side of bulk Co_2CrAl [shown by bold solid line in Fig. 6(d)] has the Δ_1 symmetry, and the doubly degenerate conduction bands have the Δ_5 symmetry. We have confirmed that the conduction band with Δ_1 symmetry dominated the tunneling and that the transmittance from the Δ_1 band was three orders of magnitude larger than that from the Δ_5 band owing to the symmetry compatibility with MgO complex bands within the energy gap. Similar to this, the majority-spin band across the Fermi level of bulk Co_2CrAl has Δ_2 symmetry, and the wave function shows a rapid decay in the MgO barrier.

Figures 7(a) and 7(b) plot the majority-spin transmittance at the Fermi level for the CMS/MgO/CMS and CCA/MgO/CCA, respectively, as a function of the in-plane wave vector $k_{\parallel}=(k_x, k_y)$. A peak centered at $k_{\parallel}=(0,0)$ is found in the k_{\parallel} dependence of the CMS/MgO/CMS owing to the coherent

tunneling through the Δ_1 channel. On the other hand, the transmittance for the CCA/MgO/CCA has no peak at $k_{\parallel}=(0,0)$ and shows spiky structures in the two-dimensional (2D) Brillouin zone, which was so-called *hot spot* conductance and attributed to the resonant tunneling between the interface states.³⁷ The averaged conductance over the 2D Brillouin zone for the CCA/MgO/CCA is about $5.55 \times 10^{-11}G_0$, which is much smaller than $1.55 \times 10^{-6}G_0$ for the CMS/MgO/CMS, where G_0 is e^2/h unit. This large difference in the k_{\parallel} dependence of the transmittance can be understood by considering the majority-spin band structures of the Co_2MnSi and Co_2CrAl around the Fermi level.

In bulk Co_2YZ ($YZ=\text{MnSi}$ and CrAl), the Δ_1 band is unoccupied or partially occupied depending on the number of valence electrons of Co_2YZ . This can be understood in terms of the well-known Slater-Pauling behavior of the total magnetization $M_T=Z_v-24$, where Z_v is the number of valence electrons and 24 means 12 occupied states per spin in Co_2YZ .⁸ In this picture, the occupancy of the minority-spin bands of Co_2YZ does not change and the extra electrons depending on Y and Z atoms fill the majority-spin bands only. Since Co_2MnSi ($Z_v=29$) has two additional valence electrons as compared with Co_2CrAl ($Z_v=27$), the Fermi level shifts to higher energies with increasing Z_v in the majority-spin state. As a result, the majority-spin Δ_1 band is partially occupied for Co_2MnSi and unoccupied for Co_2CrAl . From the chemical trend in the majority-spin band dispersions of Co-based full Heusler alloys, the position of the Fermi level is classified by Z_v as follows: the Fermi level crosses the Δ_1 bands for $Z_v \geq 28.0$, while it is positioned around the localized d bands with the Δ_2 symmetry for $Z_v < 28.0$. Thus, it can be concluded that Co_2MnAl ($Z_v=28$), Co_2MnSi ($Z_v=29$), Co_2MnGe ($Z_v=29$), Co_2FeAl ($Z_v=29$), $\text{Co}_2\text{Fe}(\text{Al}_{0.5}\text{Si}_{0.5})$ ($Z_v=29.5$), and Co_2FeSi ($Z_v=30$) will show coherent tunneling through the Δ_1 channel in the parallel magnetization, while Co_2VAl ($Z_v=26$), Co_2VGa ($Z_v=26$), Co_2CrAl ($Z_v=27$), and Co_2CrGa ($Z_v=27$) show *hot-spot* tunneling in MgO-based MTJs even in the parallel magnetization.

Then, we discuss the minority-spin transmittance of the MTJs. The dashed lines in Figs. 6(a) and 6(b) show the minority-spin transmittance at $k_{\parallel}=(0,0)$ for the CMS/MgO/CMS and CCA/MgO/CCA. It is found that the minority-spin transmittance around the Fermi energy becomes zero because of the half-metallic character of bulk Co_2MnSi and Co_2CrAl . In addition, the threshold energy of the transmittance at $k_{\parallel}=(0,0)$ (~ 1 eV) is larger than the conduction-band edge (~ 0.5 eV above the Fermi level) in the DOS of the bulk Co_2YZ (see Figs. 4 and 5). This is an advantage of MTJs with MgO barrier over MTJs with Al-O barrier because in the latter, all channels in the minority-spin state can contribute equally to the transmittance and degrade the TMR.

D. Electronic and transport properties of $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}/(\text{Co}_2\text{CrAl})_1/\text{Co}_2\text{MnSi}$

Recent experiments on the TMR measurements for the MTJs with MgO and Co-based full Heusler alloys show rela-

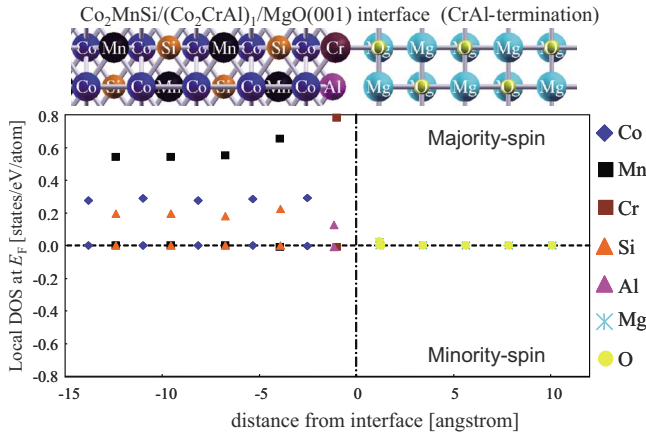


FIG. 8. (Color online) The local density of states at the Fermi level projected on to each atomic sphere as a function of the distance along [001] for the $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}(001)$ junction. The positive (negative) sign of y axis indicates majority-spin (minority-spin) LDOS. A schematic figure of the $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}(001)$ junction is shown above the LDOS.

tively large TMR ratio at low temperature.^{23–25} However, the tunneling conductance in the antiparallel magnetization increases with increasing temperature, leading to the significant reduction of the TMR ratio at RT in the MTJs. Mavropoulos *et al.*²⁸ have pointed out that spin mixing process, such as magnon excitations and inelastic scattering through interface states, is one possible reason for the tunneling conductance in the antiparallel magnetization at RT. We consider that the half-metallic character of the $\text{Co}_2\text{CrAl}/\text{MgO}(001)$ interface presented in this work will be effective to suppress the tunneling conductance through interface states in the antiparallel magnetization. However, the $\text{Co}_2\text{CrAl}/\text{MgO}/\text{Co}_2\text{CrAl}(001)$ MTJ shows considerably small tunneling conductance in the parallel magnetization owing to the absence of the Δ_1 band around the Fermi level in the Co_2CrAl . The presence of the Δ_1 band in the majority-spin state is also essential to obtain a large tunneling conductance in the parallel magnetization for the MgO-based MTJs. In addition, it is reported that the bulk Co_2CrAl is thermodynamically unstable resulting in the phase separation at RT.³⁸ Thus, the Co_2CrAl is unfavorable as an electrode of the MgO-based MTJ.

In order to utilize the half-metallic character of the CrAl termination with preserving the coherent tunneling through the Δ_1 channel, we inserted one monolayer of Co_2CrAl between Co_2MnSi electrode and MgO barrier. Figure 8 shows majority- and minority-spin LDOS at the Fermi level of the $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}(001)$ junction projected on to each atomic sphere as a function of the distance from the interface. It is found that the junction has no interface states in the minority-spin states, i.e., one monolayer of Co_2CrAl is enough to eliminate the interface states in the minority-spin gap. Furthermore, the LDOSs of the interfacial Cr, Mn, Si, and Al in Figs. 9(a) and 9(b) show clear gap in the minority-spin state, indicating the half-metallic behavior of the CrAl-terminated $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}(001)$ interface.

Figure 10 shows the in-plane wave vector (k_{\parallel}) dependence

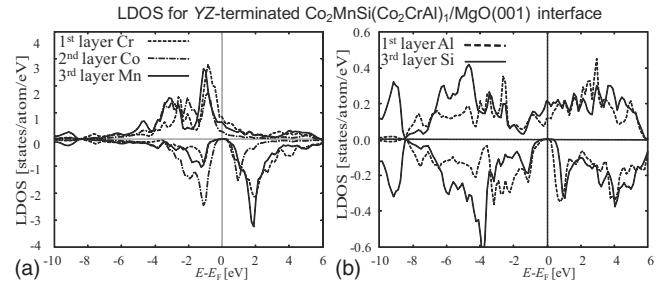


FIG. 9. (a) The local density of states of the first layer Cr (dashed lines), the second layer Co (long dashed dotted lines), and the third layer Mn (solid lines) from the $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}(001)$ interface as a function of energy relative to the Fermi energy. (b) The LDOS of the first layer Al (dashed lines) and the third layer Si (solid lines) from the $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}(001)$ interface as a function of energy relative to the Fermi energy. The sign of LDOS indicates the majority-spin (positive) and minority-spin (negative) states.

of the majority-spin transmittance at the Fermi level for the $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}(9)/(\text{Co}_2\text{CrAl})_1/\text{Co}_2\text{MnSi}(001)$ MTJ (CMS/CCA₁/MgO/CCA₁/CMS). We can find a broad peaked structure caving around $k_{\parallel}=(0,0)$. The caving structure around $k_{\parallel}=(0,0)$ indicates that the Co_2CrAl adlayer decreases the transmittance through the Δ_1 channel of the MTJ. The averaged conductance over 2D k_{\parallel} is about $6.42 \times 10^{-8}G_0$, which is smaller than $1.55 \times 10^{-6}G_0$ for the CMS/MgO/CMS, but much larger than $5.55 \times 10^{-11}G_0$ for the CCA/MgO/CCA. Furthermore, we show in Fig. 11 that the energy dependence of the transmittance at $k_{\parallel}=(0,0)$ for the CMS/CCA₁/MgO/CCA₁/CMS. We can find an abrupt decrease in the majority-spin transmittance around ~ -0.1 eV which is due to fast decay of the wave function with the Δ_1 symmetry at the Co_2CrAl adlayer. However, the energy range with nonzero transmittance is almost the same with that of the Δ_1 band of bulk Co_2MnSi in both majority- and minority-spin states. These results suggest that a MTJ having $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}$ junction can retain the coherent tunneling through the Δ_1 channel in the parallel magnetization.

We have confirmed that the junction with two-monolayer Co_2CrAl between Co_2MnSi electrode and MgO barrier also

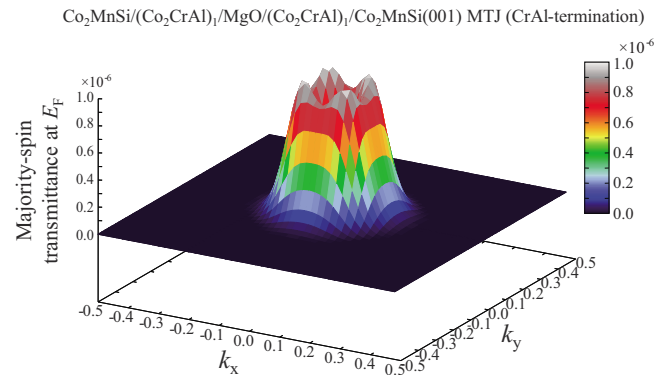


FIG. 10. (Color online) In-plane wave vector $k_{\parallel}=(k_x, k_y)$ dependence of majority-spin transmittance at the Fermi level for the $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}(9)/(\text{Co}_2\text{CrAl})_1/\text{Co}_2\text{MnSi}(001)$ MTJ in the parallel magnetization.

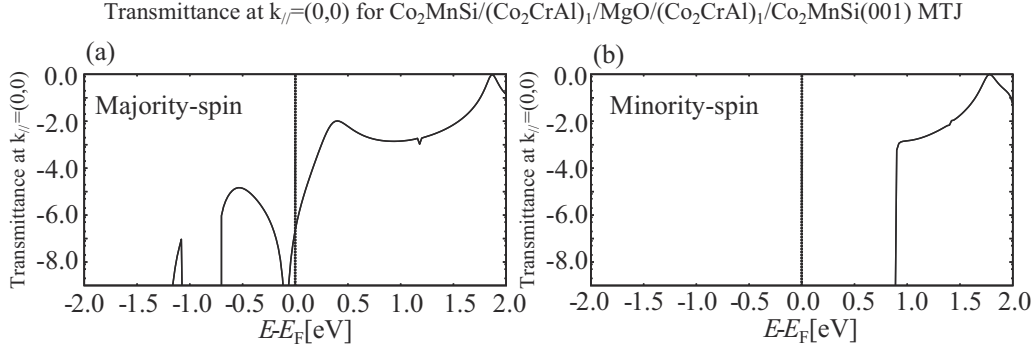


FIG. 11. Transmittance at $k_{\parallel}=(0,0)$ as a function of energy for $\text{Co}_2\text{MnSi}/(\text{Co}_2\text{CrAl})_1/\text{MgO}/(\text{Co}_2\text{CrAl})_1/\text{Co}_2\text{MnSi}(001)$ MTJ in the parallel magnetization for the (a) majority- and (b) minority-spin channels, respectively. The scale of the vertical axis is logarithmic.

shows half-metallic character and retains the coherent tunneling through the Δ_1 channel. Fabrication of half-metallic $\text{Co}_2\text{MnSi}/\text{Co}_2\text{CrAl}/\text{MgO}(001)$ junctions will be possible experimentally by depositing an ultrathin Co_2CrAl layer on Co_2MnSi electrode or MgO barrier. The half-metallic $\text{Co}_2\text{MnSi}/\text{Co}_2\text{CrAl}/\text{MgO}(001)$ junction will contribute to suppress the tunneling conductance in the antiparallel magnetization through interface states which are possible reasons for the large temperature dependence of TMR ratios observed in experiments. Our proposal will be effective also for spin injection into nonmagnetic semiconductors through MgO barrier such as $\text{Co}_2\text{MnSi}/\text{MgO}/\text{GaAs}(001)$.³⁹

Finally, we generalize our results as follows: As mentioned in Sec. III B, the presence of partially occupied majority-spin $3d$ states in Co_2YZ plays an important role for the half-metallic character at interfaces with MgO . This means that other half-metallic Co_2YZ having partially occupied $3d$ states such as $\text{Co}_2\text{CrGa}(Z_v=27)$ could be half-metallic at the junction with MgO . Furthermore, the occupancy of $3d$ bands and Δ_1 band in the majority-spin state of Co_2YZ is characterized by the number of valence electrons. Thus, MTJs having an ultrathin $\text{Co}_2YZ(Z_v \approx 27)$ layer between MgO barrier and $\text{Co}_2YZ(Z_v \geq 28)$ electrode, i.e., $\text{Co}_2YZ(Z_v \geq 28)/\text{Co}_2YZ(Z_v \approx 27)/\text{MgO}(001)$ junctions, will have half-metallic interfaces and coherent tunneling conductance through the Δ_1 channel.

IV. SUMMARY

In this paper, we have studied electronic and transport properties of MTJs with $\text{Co}_2YZ(YZ=\text{MnSi}, \text{CrAl})$ and MgO barrier on the basis of the first-principles density-functional calculations. The results show that the YZ terminations of the $\text{Co}_2YZ/\text{MgO}(001)$ junctions are thermodynamically stable as compared with the Co terminations as a result of relaxation of atomic positions in the YZ -terminated interfaces. In par-

ticular, the CrAl -terminated $\text{Co}_2\text{CrAl}/\text{MgO}(001)$ interface is half-metallic in both sides of the junctions, while the MnSi -terminated $\text{Co}_2\text{MnSi}/\text{MgO}(001)$ interface loses the half-metallicity of Co_2MnSi . We have concluded that the charge transfer from minority- to majority-spin states in $\text{Cr } 3d_\epsilon$ plays an important role to make the half-metallic gap in the CrAl -terminated $\text{Co}_2\text{CrAl}/\text{MgO}$ junction. Furthermore, conductance of the $\text{Co}_2\text{CrAl}/\text{MgO}/\text{Co}_2\text{CrAl}(001)$ MTJ is much smaller than that of the $\text{Co}_2\text{MnSi}/\text{MgO}/\text{Co}_2\text{MnSi}(001)$ MTJ in the parallel magnetization. Transport properties of $\text{Co}_2YZ/\text{MgO}/\text{Co}_2YZ(001)$ MTJs are explained by the electronic structure of bulk Co_2YZ along $[001]$, i.e., the position of the Δ_1 band relative to the Fermi energy, which changes according to the number of valence electrons. On the basis of these results, we have proposed that addition of an ultrathin Co_2CrAl layer between Co_2MnSi electrode and MgO barrier, i.e., $\text{Co}_2\text{MnSi}/\text{Co}_2\text{CrAl}/\text{MgO}(001)$ junction, is effective to eliminate interface states in both sides of the junction while preserving the coherent tunneling through the Δ_1 channel of the MTJ in the parallel magnetization. Finally, we have generalized our proposal to $\text{Co}_2YZ(Z_v \geq 28)/\text{Co}_2YZ(Z_v \approx 27)/\text{MgO}(001)$ junctions. All these findings suggest that half-metallic character at interfaces and transport properties of MTJs with MgO and Co_2YZ can be designed by controlling their junctions, and that is worth further investigations.

ACKNOWLEDGMENTS

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